



Serial No. 09/605,660
SEC. 736

#6 Election
9/16/03

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION of

Choung Hyep KIM et al.

Serial No.: 09/605,660

Filed: June 28, 2000

Group Art Unit: 2825

Examiner: Yevsikov, Victor V.

For: APPARATUS FOR AND METHOD OF HEAT-TREATING A WAFER

RESPONSE TO ELECTION/RESTRICTION REQUIREMENT

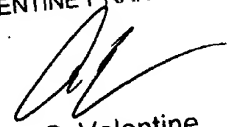
U.S. Patent and Trademark Office
2011 South Clark Place
Customer Window, Mail Stop Non Fee Amendment
Crystal Plaza Two, Lobby, Room 1B03
Arlington, VA 22202

Sir:

In response to the Office Action of August 19, 2003, Applicants elect the invention of Group II, Claims 6-9, drawn to a method for temperature conditioning a wafer. The election is without traverse.

Respectfully submitted,

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Dated: September 16, 2003

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